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Commercial and Biomedical Applications of Ultrafast Lasers IX

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Contents

| vii | Conference Committee |
|---------|--|
| | |
| | MULTIPHOTON IMAGING AND GUIDED SURGERY |
| 7203 06 | New developments in two-photon analysis of human skin in vivo (Invited Paper) [7203-05] I. Riemann, M. Schwarz, F. Stracke, A. Ehlers, Fraunhofer Institute of Biomedical Technology (Germany); E. Dimitrow, M. Kaatz, Friedrich-Schiller-Univ. Jena (Germany); K. König, JenLab GmbH (Germany); R. Le Harzic, Fraunhofer Institute of Biomedical Technology (Germany) |
| 7203 07 | OCT-aided femtosecond laser micromachining device [7203-06] O. Massow, Laser Zentrum Hannover e.V. (Germany); M. Jackstadt, Rowiak GmbH (Germany); H. Wisweh, Laser Zentrum Hannover e.V. (Germany); F. Will, Rowiak GmbH (Germany); H. Lubatschowski, Laser Zentrum Hannover e.V. (Germany) and Rowiak GmbH (Germany) |
| 7203 09 | Near infrared femtosecond laser ablation of urinary calculi in water [7203-08] J. Qiu, The Univ. of Texas at Austin (United States); J. M. Teichman, The Univ. of British Columbia (Canada); R. V. Kuranov, A. B. McElroy, Volcano Corp. (United States); T. Wang, A. S. Paranjape, T. E. Milner, The Univ. of Texas at Austin (United States) |
| | LASER APPLICATION IN MICRO-ORGANISMS AND BIOTECHNOLOGY |
| 7203 OB | Probing cilia-driven flow in living embryos using femtosecond laser ablation and fast imaging (Invited Paper) [7203-10] W. Supatto, S. E. Fraser, J. Vermot, California Institute of Technology (United States) |
| 7203 OC | Femtosecond laser scalpel technology for proteomic mass spectrometry [7203-11] C. L. Kalcic, T. C. Gunaratne, G. E. Reid, A. D. Jones, M. Dantus, Michigan State Univ. (United States) |
| 7203 OE | High-throughput on-chip in vivo neural regeneration studies using femtosecond laser nano-surgery and microfluidics (Invited Paper) [7203-42] C. B. Rohde, F. Zeng, C. Gilleland, C. Samara, M. F. Yanik, Massachusetts Institute of Technology (United States) |
| | LASER DIRECT-WRITTEN DEVICES I |
| 7203 0G | Femtosecond laser direct written diffractive optical elements and their integration in oxide glass [7203-13] J. Choi, M. Richardson, College of Optics and Photonics, Univ. of Central Florida (United States) |

7203 0H Evanescently coupled fs laser-written type II waveguide array in lithium niobate [7203-14] M. Heinrich, F. Dreisow, A. Szameit, J. Thomas, S. Döring, S. Nolte, Friedrich-Schiller-Univ. Jena (Germany); A. Tünnermann, Friedrich-Schiller-Univ. Jena (Germany) and Fraunhofer Institute for Applied Optics and Precision Engineering (Germany); A. Ancona, CNR-INFM Regional Lab. LIT (Italy)

7203 01 Integrating optics and micro-fluidic channels using femtosecond laser irradiation (Invited Paper) [7203-15]

T. Anderson, College of Optics and Photonics, Univ. of Central Florida (United States); J. Hu, Massachusetts Institute of Technology (United States); M. Ramme, J. Choi, College of Optics and Photonics, Univ. of Central Florida (United States); C. Faris, Coe College (United States); N. Carlie, Clemson Univ. (United States); A. Agarwal, Massachusetts Institute of Technology (United States); L. Petit, Clemson Univ. (United States); L. Kimerling, Massachusetts Institute of Technology (United States); K. Richardson, Clemson Univ. (United States); M. Richardson, College of Optics and Photonics, Univ. of Central Florida (United States)

LASER DIRECT-WRITTEN DEVICES II

7203 0K Self imaging in segmented waveguide arrays [7203-17]

M. Heinrich, A. Szameit, F. Dreisow, T. Pertsch, S. Nolte, Friedrich-Schiller-Univ. Jena (Germany); A. Tünnermann, Friedrich-Schiller-Univ. Jena (Germany) and Fraunhofer Institute for Applied Optics and Precision Engineering (Germany); E. Suran, F. Louradour, A. Bathélémy, XLIM Institut de Recherche, CNRS, Univ. de Limoges (France); S. Longhi, IFN-CNR, Politecnico di Milano (Italy)

7203 0M High strength fused silica flexures manufactured by femtosecond laser [7203-19]

Y. Bellouard, Eindhoven Univ. of Technology (Netherlands); A. A. Said, M. Dugan, P. Bado, Translume, Inc. (United States)

INTERACTION OF MATTER WITH ULTRASHORT PULSES

7203 00 **Femtosecond laser surface structuring of biocompatible metals** [7203-21] A. Y. Vorobyev, C. Guo, The Institute of Optics, Univ. of Rochester (United States)

7203 0R High speed structuring of CIS thin-film solar cells with picosecond laser ablation [7203-24] H. P. Huber, M. Englmaier, C. Hellwig, A. Heiss, T. Kuznicki, M. Kemnitzer, Munich Univ. of Applied Sciences (Germany); H. Vogt, R. Brenning, J. Palm, AVANCIS GmbH & Co. KG (Germany)

LASER SOURCES AND CHARACTERIZATION

7203 0T Ultrafast Yb:YAG thin-disk oscillator with pulse energies exceeding 25 µJ suitable for efficient ablation with negligible heat affects [7203-26]

J. Neuhaus, D. Bauer, TRUMPF Laser GmbH & Co. KG (Germany) and Univ. of Konstanz (Germany); C. Scharfenberg, D. H. Sutter, J. Kleinbauer, S. Weiler, A. Killi, TRUMPF Laser GmbH & Co. KG (Germany); T. Dekorsy, Univ. of Konstanz (Germany)

7203 0U **High-energy and high-power Yb:KGW femtosecond regenerative amplifier** [7203-27] T. Miura, S. Ito, OMRON Laserfront Inc. (Japan)

7203 0V Ultrafast heterodyne optical sampling applied to picosecond ultrasonics and nanoscale heat transfer [7203-28]

E. Mottay, P. Rigail, Amplitude Systemes (France); C. Pierre, S. Ermeneux, ALPhANOV (France); J.-M. Rampnoux, S. Dilhaire, Univ. Bordeaux (France)

7203 0W Femtosecond fiber laser system for medical applications [7203-29]

C. Hönninger, JT Optical Engine GmbH & Co. KG (Germany); M. Plötner, B. Ortaç, R. Ackermann, R. Kammel, J. Limpert, S. Nolte, A. Tünnermann, Friedrich-Schiller-Univ. Jena (Germany)

7203 0X Measuring the spatiotemporal electric field of tightly focused ultrashort pulses with submicron spatial resolution [7203-30]

P. Bowlan, Georgia Institute of Technology (United States); U. Fuchs, Fraunhofer-Institut für Angewandte Optik und Feinmechanik (Germany); R. Trebino, Georgia Institute of Technology (United States); U. D. Zeitner, Fraunhofer-Institut für Angewandte Optik und Feinmechanik (Germany)

7203 0Y When shorter is better [7203-31]

V. Lozovoy, Michigan State Univ. (United States); M. Dantus, Michigan State Univ. (United States) and BioPhotonic Solutions Inc. (United States)

7203 0Z Single grism pulse compressor [7203-32]

V. Chauhan, P. Bowlan, Georgia Institute of Technology (United States); E. Miesak, Lockheed Martin Corp. (United States); S. Kane, HORIBA Jobin Yvon, Inc. (United States); R. Trebino, Georgia Institute of Technology (United States)

JOINT SESSION WITH CONFERENCE 7201: FEMTOSECOND LASER PROCESSING

7203 11 Ultrashort pulse laser drilling of metals using a high-repetition rate high average power fiber CPA system (Invited Paper) [7203-33]

A. Ancona, Friedrich-Schiller-Univ. of Jena (Germany) and CNR-INFM Regional Lab. LIT (Italy); C. Jauregui, S. Döring, F. Röser, J. Limpert, S. Nolte, Friedrich-Schiller-Univ. of Jena (Germany); A. Tünnermann, Friedrich-Schiller-Univ. of Jena (Germany) and Fraunhofer Institute for Applied Optics and Precision Engineering (Germany)

7203 12 Towards a femtosecond laser micromachined optofluidic device for distinguishing algae species (Invited Paper) [7203-34]

Y. Bellouard, V. K. Pahilwani, Eindhoven Univ. of Technology (Netherlands); T. Rohrlack, Norwegian Institute for Water Research (Norway); A. A. Said, M. Dugan, P. Bado, Translume, Inc. (United States)

7203 13 Three-dimensional photonic devices fabricated by ultrafast lasers for optical sensing in lab-on-a-chip [7203-35]

R. Martínez Vázquez, R. Osellame, A. Crespi, IFN-CNR, Politecnico di Milano (Italy); C. Dongre, H. J. W. M. Hoekstra, M. Pollnau, Univ. of Twente (Netherlands); H. H. van den Vlekkert, R. van Weeghel, LioniX BV (Netherlands); P. Watts, The Univ. of Hull (United Kingdom); R. Ramponi, G. Cerullo, IFN-CNR, Politecnico di Milano (Italy)

JOINT SESSION WITH CONFERENCE 7201: DIAGNOSTICS OF LASER-WRITTEN DEVICES

7203 17 Optical coherence microscopy for nondestructive 3D imaging of femtosecond laser written structures [7203-39]

J. Choi, K.-S. Lee, S. Murali, T. Anderson, J. P. Rolland, M. C. Richardson, College of Optics and Photonics, Univ. of Central Florida (United States)

Author Index

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- Light Interaction with Cells and Plasmonics Ablation
 Joseph Neev, JYN Industries Inc. (United States)
- 2 Multiphoton Imaging and Guided Surgery Alfred Vogel, Universität zu Lübeck (Germany)
- 3 Laser Application in Micro-Organisms and Biotechnology **Alexander Heisterkamp**, Laser Zentrum Hannover e.V. (Germany)
- 4 Laser Direct-Written Devices I

 Alexander Szameit, Friedrich-Schiller-Universität Jena (Germany)
- Laser Direct-Written Devices II
 Christopher B. Schaffer, Cornell University (United States)
- 6 Interaction of Matter with Ultrashort Pulses
 Eric P. Mottay, Amplitude Systemes (France)
- Laser Sources and Characterization
 Rick P. Trebino, Georgia Institute of Technology (United States)
- 8 Joint Session with Conference 7201: Femtosecond Laser Processing Stefan Nolte, Friedrich-Schiller-Universität Jena (Germany)
- 9 Joint Session with Conference 7201: Diagnostics of Laser-Written Devices
 - **Wataru Watanabe**, National Institute of Advanced Industrial Science and Technology (Japan)